AMENDMENTS TO THE CLAIMS

This listing of claims will replace all prior versions and listings of claims in the application:

LISTING OF CLAIMS:

- 1. (currently amended): A silica glass member for use in a plasma reaction apparatus for producing a semiconductor or a liquid crystal display using a halogen-containing compound gas and a plasma thereof, which is composed of a highly durable plasma resistant-silica glass consisting essentially of silica and 0.01% to 2% by weight, based on the weight of the silica glass, of at least one element selected from the group consisting of magnesium, calcium, strontium, barium, yttrium, hafnium and zirconium, which exhibits a rate of etching lower than that of an otherwise identical silica glass free of said at least one element.
- 2. (previously presented): The silica glass member according to claim 1, wherein the content of said at least one element is in the range of 0.05% to 0.5% by weight based on the weight of the silica glass.
- 3. (currently amended): The silica glass member according to claim 1, wherein said at least one element is zirconium and the silica glass is transparent.
- 4. (currently amended): The silica glass member according to claim 1, wherein said <u>at</u> <u>least one element</u> is zirconium and the silica glass exhibits a variant coefficient of zirconium

2

AMENDMENT UNDER 37 C.F.R. § 1.111 U.S. Appln. No. 10/718,575

concentration as measured on plural micro-regions by an EPMA (X-ray micro analyzer) in the range of 0.1% to 100%; said variant coefficient being defined by the following equation:

Variant coefficient(%)= $\sigma/C \times 100$

wherein o is standard deviation and C is concentration of zirconium.

- 5. (previously presented): The silica glass member according to claim 1, which is a flange of a reaction tube.
- 6. (previously presented): The silica glass member according to claim 1, which is a bell jar.
- 7. (withdrawn): A semiconductor-producing apparatus equipped with a silica glass member as claimed in claim 1.
- 8. (withdrawn): The semiconductor-producing apparatus according to claim 7, wherein said silica glass member is a flange of a reaction tube.
- 9. (withdrawn): The semiconductor-producing apparatus according to claim 7, wherein said silica glass member is a bell jar.

AMENDMENT UNDER 37 C.F.R. § 1.111 U.S. Appln. No. 10/718,575

10. (withdrawn): A liquid crystal-producing apparatus equipped with a silica glass member as claimed in claim 1.

11. (withdrawn): The liquid crystal-producing apparatus according to claim 10, wherein said silica glass member is a flange of a reaction tube.

12. (withdrawn): The liquid crystal-producing apparatus according to claim 10, wherein said silica glass member is a bell jar.

Claims 13 to 34 (cancelled).